

	AA	U.S. Patent 5,638,447
	AB	U.S. Patent 5,402,490
20	AI	International application WO 97/48208
	AJ	French reference FR 2 709 903
	AK	International application WO 95/14283
	AL	Japanese reference JP 09-298537
25	AQ	W. Fumy et al., "Kryptographie, Entwurf und Analyse symmetrischer Kryptosysteme, R. Oldenbourg Verlag Muenchen Wien 1988, ISBN 3-486-20868-3 pages 287-291

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5 Reference AQ has been described on page 1 of the present application. Accordingly, no further commentary concerning the teachings of this references are believed to be necessary.

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Respectfully submitted,

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Sheet 1 of 1

Form P.T.O. 1449		U.S. Department of Commerce Patent and Trademark Office			Docket No. P00,0637		Serial No. New Application	
LIST OF PRIOR ART CITED BY APPLICANT (use several sheets if necessary)					Applicant(s) Anton Enterrottacher et al.			
					Filing Date Herewith		Group Art Unit	
U.S. PATENT DOCUMENTS								
Examiner's Initials		Document Number	Date	Name	Class	Subclass	Filing Date If appropriate	
	AA	5,638,447	10 Jun 1997	Micali				
	AB	5,402,490	28 Mar 1995	Mihm, Jr.				
	AC							
	AD							
	AE							
	AF							
	AG							
	AH							
FOREIGN PATENT DOCUMENTS								
		Document Number	Date	Country	Class	Subclass	Translation	
							Yes	No
	AI	WO 97/48208	18 Dec 1997	PCT				
	AJ	FR 2 709 903	17 Mar 1995	France				
	AK	WO 95/14283	26 May 1995	PCT				
	AL	JP 09-298537	18 Nov 1997	Japanese				
	AM							
	AN							
	AO							
	AP							
OTHER PRIOR ART (Including Author, Title, Date, Pertinent Pages, Etc.)								
	AQ	W. Fumy et al., "Kryptographie, Entwurf und Analyse symmetrischer Kryptosysteme, R. Oldenbourg Verlag Muenchen Wien 1988, ISBN 3-486-20868-3 pages 287-291						
	AR							
	AS							
	AT							
	AU							
	AV							
Examiner				Date Considered				
<p>*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.</p>								